

PATENT APPLICA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

January 23, 2003

In re the Application of

Shunichi SEKI et al.

Application No.:

Filed:

For:

09/701,534

November 30, 2000

Group Art Unit:

1762

Examiner:

M. Cleveland

ECHNOLOGY CENTER 1700

Docket No.:

107291

LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION OF TIME UNDER 37 C.F.R. §1.136(a) AND TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17

METHOD FOR FORMING SILICON FILM AND INK COMPOSITION FOR INK JET

Director of the U.S. Patent and Trademark Office Washington, D.C. 20231

Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired October 23, 2002, an extension of time for a period of three months is hereby requested. Attached hereto is our Check No. 138352 in the amount of \$930.00 in payment for:

	Extension fee for response within first month pursuant to §1.136(a) (\$110.00)
	Extension fee for response within second month pursuant to §1.136(a) (\$410.00)
X	Extension fee for response within third month pursuant to §1.136(a) (\$930.00)

The Director is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

Respectfully submitted

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DEPOSIT ACCOUNT USE **AUTHORIZATION** Please grant any extension necessary for entry; Charge any fee due to our

Deposit Account No. 15-0461